S/N 10/081,818 PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Jerome M. Eldridge et al. Examiner: Tu-Tu V. Ho

 Serial No.:
 10/081,818
 Group Art Unit: 2818

 Filed:
 February 20, 2002
 Docket No.: 1303.045US1

Title: ATOMIC LAYER DEPOSITION OF METAL OXIDE AND/OR LOW ASYMMETRICAL TUNNEL BARRIER INTERPLOY INSULATORS

AMENDMENT AND RESPONSE UNDER 37 CFR § 1.111

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

This responds to the Office Action mailed on March 14, 2008. Please amend the aboveidentified patent application as follows.